

Institute of Fluid Science Green Nano Technology Division Endo Laboratory

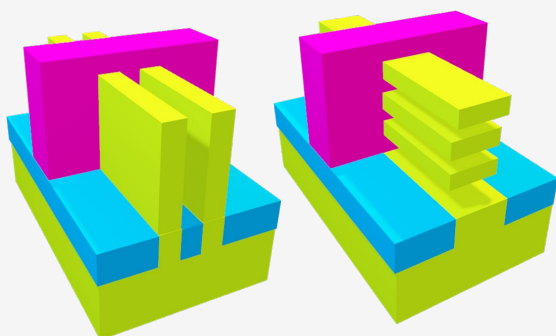
Professor: Kazuhiko Endo
Specially Appointed
Assistant Professor:
Daisuke Ohori



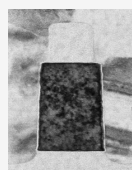
Opened on November 1st , 2022

Endo laboratory aims to control the flow of information and energy with semiconductor technology. Among semiconductor technologies, we aim to improve performance and break through technological limitations by introducing new processes, new materials, new deposition methods, and new structures for fine silicon nanodevices.

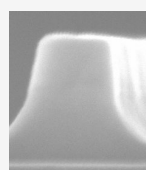
We will utilize the National Institute of Advanced Industrial Science and Technology (AIST) in Japan and the Joint Laboratory of National Yang-Ming Chiao Tung University in Taiwan as a base for semiconductor device research. Opportunities for overseas assignments in Taiwan, the U.S., and other countries are also available.



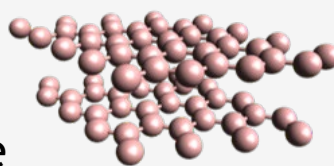
Advanced Silicon Nanodevice



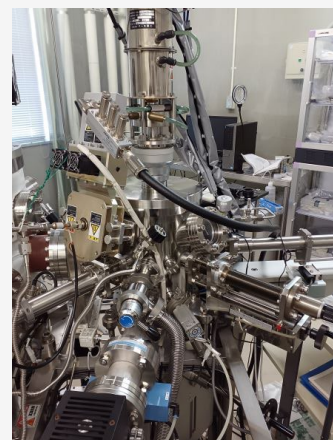
Si



Ge



2D material



Process
Equipment